Finite Element Analysis of the Effects of Package Induced Stress on Micromechanical Resonator Temperature Stability

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Finite Element Analysis of the Effects of Package Induced Stress on Micromechanical Resonator Temperature Stability

by Divya Kashyap

Research Project

Submitted to the Department of Electrical Engineering and Computer Sciences, University of California at Berkeley, in partial satisfaction of the requirements for the degree of Master of Science, Plan II.

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(Date)
# Table of Contents

Table of Contents .............................................................................................................................................. ii
Acknowledgements ................................................................................................................................................ iii
Abstract ............................................................................................................................................................ iv
Introduction ....................................................................................................................................................... 1
Finite Element Analysis ........................................................................................................................................ 5
  Static Structural analysis of the package model ............................................................................................... 5
  Strain on the surface of packaged die at -45 °C ............................................................................................... 7
    Boundary Conditions and Applied loads ....................................................................................................... 7
    Determining resonator anchor displacement expressions ............................................................................. 7
  Plastic Encapsulation ....................................................................................................................................... 9
  Die Attach ....................................................................................................................................................... 9
  Wafer Level Bond .......................................................................................................................................... 10
  Low Pressure Chemical Vapor Deposition (LPCVD) of Polysilicon .............................................................. 11
  Total Lateral Deformation at -45 °C ................................................................................................................. 11
  Strain of packaged die across the operational temperature range ................................................................. 12
  Temperature dependence of resonant frequency ............................................................................................ 14
Temperature Stability Results ............................................................................................................................ 20
Conclusion .......................................................................................................................................................... 21
References .......................................................................................................................................................... 25
Appendix A ....................................................................................................................................................... 27
Appendix B ....................................................................................................................................................... 28
Appendix C ....................................................................................................................................................... 29
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iii
Abstract

Vacuum encapsulation of RF disk and beam resonators is often needed to maintain high quality factor and frequency stability. Conventionally, this is performed at the wafer level by anodic, eutectic, fusion, or glass frit bonding. After wafer dicing, packaging proceeds with die attach to the package substrate and plastic over molding. This process leads to many contacts between materials of different coefficients of thermal expansion (CTE) resulting in package-induced stress. The focus of this work is to determine the effect of this stress on the temperature stability of micromechanical resonators via finite element analysis (FEA), for applications that do not require attachment to a printed circuit board, such as the sensors in the original vision of Smart Dust. The simulation is separated into two main parts: (a) package analysis and (b) resonator analysis. The package is analyzed in a static structural environment, recording mesh model nodal displacement on the packaged die surface, yielding displacement boundary conditions specific for each of the selected package models. These boundary conditions are then applied to the anchor nodes of the resonator in a separate prestressed modal analysis to determine modal frequencies of the desired mode shapes. Results indicate that package-induced stress depends mostly on die thickness and die attach CTE. Thinner dies and die attach material with very high CTEs tend to induce more stress in the die. The temperature stability of packaged resonators, when compared to their unpackaged counterparts, is influenced very slightly by the package alone. Thinner dies improve temperature stability very slightly, although there is residual stress in the die itself, which may lead to mechanical failure of the package. Of the resonator geometries investigated, the clamped-clamped beam is the most susceptible to package-induced stress, because of the large anchor contact area to the substrate. The centrally anchored disk, although directly anchored to the substrate, contacts a much smaller area, and thus, its temperature stability is unaffected by package-induced stress. Although it has large anchors, the free-free beam is levitated by support beams, and so, its temperature stability is only slightly affected. Finite element models are solved using the commercial FEA software package ANSYS 14.5.
Introduction

Standard packaging of electronic components after microfabrication on a semiconductor wafer and wafer dicing involves die attach and plastic over molding. MEMS components, however, require additional wafer level encapsulation after microfabrication to allow mechanical movement of the component. In particular, radio frequency MEMS resonators often require vacuum encapsulation for high quality factor and frequency stability. Wafer bonding processes that offer the required hermeticity at the wafer level are anodic, eutectic, fusion, and glass frit bonding [1]. Examples of commercial vacuum packaged MEMS resonators include the Discera oscillator [2] and the InvenSense gyroscope [3].

After singulation, the wafer level encapsulated die is picked up by a vacuum tool, and bonded to the package substrate (can be copper in case a heat sink is required, or more commonly, plastic or ceramic) via an adhesive called the die attach [4]. This step induces the most stress at the surface of the resonator substrate, and has been investigated extensively as to how it affects semiconductor device performance [5]. Using experimental evidence, the authors of [6] have suggested that the stress resulting from die attach can actually be used to compensate the temperature coefficient of frequency of quadruple mass gyroscopes by controlling die bond area. A four-dot die attach approach, as opposed to the full die attach approach, elaborated on in [7], proves to be less detrimental to the performance of an accelerometer. Walwadkar and Cho have looked at the effects of two types of die attach (silver glass and polyimide) on die surface stress [8]. However, a very large die size is used in [5-8], typically required of integrated circuits, accelerometers, and gyroscopes, with each side being several millimeters in length. On the other hand, an RF MEMS resonator (like the one in [9]), its electrodes and contact lines take up much less space, requiring a much smaller die.

Low Temperature Co-fired Ceramic (LTCC) has many electrical and mechanical properties favorable to RF resonators, when compared to other package substrates. It has a low loss tangent at high frequencies. Manufacturing is performed in a multilayer process, so it’s possible to embed passive circuits by printing metal traces such as resistors, capacitors, and inductors, and connecting layers through vias. Due to the low dielectric constant, the parasitic capacitance in these embedded circuits is low, minimizing crosstalk. The thermal expansion coefficient of LTCC is close to that of silicon, lowering package-induced stress on the die surface.
When wafer bonding processes are not readily accessible, or for prototype testing, when package size is not of concern, pre-made cavities and lids, manufactured from LTCC, can be used to vacuum seal MEMS resonators, by virtue of its hermetic property [9].

The objective of the simulations in this report is to evaluate the effect of package-induced stress on the temperature coefficient of frequency of the MEMS resonator. The simulations performed are linear static and material properties, listed in Table 1, are linear elastic. The package model chosen for this study measures 2.5 mm × 2.0 mm × 3.5 mm, occupying the same footprint as commercial MEMS oscillators [2]. A dimensioned 2D sketch is provided in Figure 1. Nominal thickness values are used for each component. Since this is meant to be a general package model, electrical leads are ignored. The die size permits the aforementioned wafer bonding techniques (200 μm wide seal ring), is large enough to accommodate the resonator, and can be picked up by standard die collets [13]. Two types of wafer level encapsulation are investigated: (a) silicon-to-silicon glass frit bond and (b) a glass-to-silicon anodic bond. The cavity in the silicon wafer level cap is etched at an angle of 54.7° and bonded to the resonator wafer using glass frit. For anodic bonding, the material properties of the cap wafer are changed to that of Pyrex, and since a thin layer of oxide forms as the interlayer, the material properties of the glass frit layer are replaced with that of oxide. For simplicity, the fact that the pyrex wafer cap may have a rounded profile, unlike anisotropically etched silicon, is ignored. This ensures that the resulting stress values are only a product of material properties, rather than changes in geometry. Three types of die attach are experimented with: (a) silver glass, (b) polyimide, and (c) a standard IC die attach.

<table>
<thead>
<tr>
<th>Material</th>
<th>Coefficient of Thermal Expansion [ppm/°C]</th>
<th>Young’s Modulus [GPa]</th>
<th>Poisson’s Ratio</th>
</tr>
</thead>
<tbody>
<tr>
<td>Silicon</td>
<td>2.85</td>
<td>169 at 22 °C; -60 ppm/°C</td>
<td>0.28</td>
</tr>
<tr>
<td>Pyrex</td>
<td>3.25</td>
<td>62.75</td>
<td>0.2</td>
</tr>
<tr>
<td>Glass Frit</td>
<td>6.3</td>
<td>50</td>
<td>0.22</td>
</tr>
<tr>
<td>Oxide</td>
<td>0.5</td>
<td>70</td>
<td>0.17</td>
</tr>
<tr>
<td>Silver glass [8]</td>
<td>16</td>
<td>11.5</td>
<td>0.35</td>
</tr>
<tr>
<td>Polyimide [8]</td>
<td>13</td>
<td>2.47</td>
<td>0.4</td>
</tr>
<tr>
<td>Standard die attach used in plastic IC packaging [5]</td>
<td>60</td>
<td>5</td>
<td>0.35</td>
</tr>
<tr>
<td>Ceramic [12]</td>
<td>5.8</td>
<td>120</td>
<td>0.24</td>
</tr>
<tr>
<td>Plastic [5]</td>
<td>15</td>
<td>11.5</td>
<td>0.3</td>
</tr>
<tr>
<td>Polysilicon</td>
<td>3.35</td>
<td>150 at 22 °C; -40 ppm/°C</td>
<td>0.226</td>
</tr>
</tbody>
</table>
Figure 1: 2D sketch showing dimensions (in μm) of package model.
Preliminary simulations revealed that the following package models are the most interesting both in terms of package-induced stress and the ensuing change in resonator temperature coefficient of frequency.

Table 2: Package models investigated in this study

<table>
<thead>
<tr>
<th>Package Model</th>
<th>Die Attach Material</th>
<th>Cap Wafer Material</th>
<th>Wafer Bond Material</th>
<th>Packaged die and wafer cap thickness ($t_{cap}$ and $t_{die}$) [μm]</th>
</tr>
</thead>
<tbody>
<tr>
<td>A</td>
<td>Standard die attach used in plastic IC packaging</td>
<td>Pyrex</td>
<td>Oxide</td>
<td>300</td>
</tr>
<tr>
<td>B</td>
<td>Silver glass</td>
<td>Silicon</td>
<td>Glass Frit</td>
<td>300</td>
</tr>
<tr>
<td>C</td>
<td>Silver glass</td>
<td>Silicon</td>
<td>Glass Frit</td>
<td>500</td>
</tr>
<tr>
<td>D</td>
<td>Polyimide</td>
<td>Silicon</td>
<td>Glass Frit</td>
<td>500</td>
</tr>
<tr>
<td>E</td>
<td>Standard die attach used in plastic IC packaging</td>
<td>Silicon</td>
<td>Glass Frit</td>
<td>500</td>
</tr>
<tr>
<td>F</td>
<td>Standard die attach used in plastic IC packaging</td>
<td>Pyrex</td>
<td>Oxide</td>
<td>500</td>
</tr>
</tbody>
</table>

The following sections of this report detail the procedure used to simulate resonator temperature stability in packaged and unpackaged resonators, via ANSYS 14.5 [14]. The package models are simulated and the resulting strain boundary conditions are applied to the resonator anchors. Results are presented and the conclusion section interprets the applicability of these results.
Finite Element Analysis

The objective of this study is to determine the effect of package-induced stress on resonator temperature stability by first performing a static structural analysis on the package model and then applying the deformation result to the resonator anchor in a modal analysis, as illustrated in Figure 2. The analysis is split in order to investigate the effect of one package on the behavior of various resonator geometries. In this report, geometries observed are the clamped-clamped beam, free-free beam, center-stem disk, and stemless disk levitated by four support beams.

Figure 2: Overview of the analysis carried out in this report. First, the package model (right) is simulated. Then, the displacement observed on the surface of the packaged silicon die is applied as a boundary condition in the modal analysis of the resonator. The zoomed-in view shows where the resonator (clamped-clamped beam in this figure) would be anchored on the die.

Static Structural analysis of the package model

The first step to simulating thermal stability of packaged resonators is developing a model for package induced stress that can be used as a boundary condition for the resonator. Residual stress in the package that deforms the silicon die (resonator substrate) is a result of the contact
between materials of mismatched thermal expansion coefficients and thermal strain from a high stress free temperature. In this report, it is assumed that both the resonators and the silicon die are stress free during deposition, at 600 °C, the nominal temperature for low pressure chemical vapor deposition of polysilicon. The total deformation is a sum of the individual deformations after deposition, wafer level bonding, die attach, and plastic encapsulation. Since the analysis performed for this study is static and neglects large deformation effects, results of multiple steps are independent of each other, i.e., the same sum will be obtained for simulation of the various packaging steps in any order, by the commutative property of addition. Utilizing the birth and death of elements capability (code lines in Appendix B) in ANSYS, static structural analysis on the package model begins with the last step in the package process, plastic encapsulation, and proceeds in reverse, ending with resonator deposition, by selectively killing solid and contact elements not present at the current step. For example, die attach to the ceramic substrate is modeled by killing elements that represent the plastic and its contact to other components of the package. This technique ensures that the same mesh model is used in the entire simulation, by killing elements and changing stress free temperatures through APDL command snippets, allowing the use of the “Solution Combination” feature of ANSYS Mechanical to get total deformation. Also, if the stress free temperature changes, for example, if there is an anneal step in the fabrication process, this involves modifying just one value in the entire simulation.

For all package models simulated, due to the small area of the packaged die (1620 μm x 1620 μm), die warpage is minimal, and hence, only lateral strain is explored. The following section explains the procedure to determine strain at \(-45 \, ^\circ\text{C}\) on the surface of the resonator substrate. This process is repeated for temperature values until 155 °C in increments of 40 °C.

The main cause of resonator frequency shift is the difference in stiffness due to the temperature dependence of Young’s modulus and anchor shift. Essential to all simulations is the accurate calculation of stress, whether in the packaged die or the resonator. Hence, the finite element model uses hexahedral elements, and midside nodes are included to add an extra degree of freedom of deformation on each edge, forcing the quadratic shape function on the element. Such an element is said to be the most accurate in stress calculations, according to literature [15]. The model consists of 20-node hexahedron elements (SOLID186), meshed automatically by
ANSYS Mechanical. The mesh setting is specified as “fine”, or having an element size of 0.25 μm, whichever is smaller. The contact pairs consist of CONTA174 and TARGE170 elements.

Strain on the surface of packaged die at -45 °C

Boundary Conditions and Applied loads

Modeling one quadrant of the package and designating planes of symmetry as frictionless supports, shown in Figure 3, implies symmetry. To prevent rigid body motion and set a reference to measure displacement, the center vertex of the silicon die has been fixed, also shown in Figure 3. The stressed temperature is applied as a thermal load.

Determining resonator anchor displacement expressions

Thermal stability simulations assume the resonator is centered on the packaged die. After solving a model with the applied boundary and load conditions, the resulting directional deformation is observed in the region of interest (possible anchor points of the resonator) along the scoped path indicated by the translucent purple arrow in Figure 4. The sum of these displacements from each packaging step is then used to determine strain as a function of temperature. These constraints are then applied as displacement boundary conditions.

Figure 3: A quadrant of the package model. Planes of symmetry have been designated as frictionless supports and one vertex of the silicon die is fixed to prevent rigid body motion.
conditions to the anchors of resonators in a separate model.

Figure 4: Mesh model of plastic encapsulation step of the packaging process. Deformation in the y-direction along the scoped path (where a resonator would be anchored) is recorded.
Plastic Encapsulation

Most thermoplastics cure around 150 °C, so this is chosen as the stress free temperature for plastic encapsulation. To determine packaged strain at -45 °C, the thermal condition applied to all bodies is -45 °C. All solid and contact elements are alive, as shown in Figure 4. The plot on the right shows the y-direction deformation at -45 °C caused by plastic molding along the scoped path.

Die Attach

To simulate deformation caused by die attach, the plastic solid elements and its contacts to other bodies are killed. The effective mesh model then looks as shown on the left. The stress free temperature for all elements is chosen to be 350 °C. Since the next step is plastic encapsulation, whose stress free temperature is 150 °C, this is the applied thermal load. Results are plotted below.
Wafer Level Bond

Hermetic wafer level encapsulation, such as anodic and glass frit bonding, normally occurs at 450 °C, the stress free temperature for this step. Since the next step, die attach, happens at 350 °C, this is the applied thermal condition. After killing the plastic, die attach, and ceramic elements and their contacts, the mesh model reduces to the one on the left. Directional deformation results are shown in Figure 9.

Figure 8: Mesh model for wafer level bond

![Mesh model for wafer level bond](image)

Figure 9: Directional deformation along the y-axis caused by wafer level bond

![Directional deformation graph](image)
Low Pressure Chemical Vapor Deposition (LPCVD) of Polysilicon

The structural material for resonators of this work, polysilicon, is deposited at 600 °C, the stress-free temperature for this step. The effective mesh here comprises just the silicon die (Figure 10), and the applied temperature is 450 °C. Directional deformation results are shown in Figure 11.

![Mesh model for LPCVD](image.png)

**Figure 10: Mesh model for LPCVD**

![Directional deformation](image.png)

**Figure 11: Directional deformation along the y-axis caused by LPCVD**

**Total Lateral Deformation at -45 °C**

Using the “Solution Combination” feature of ANSYS Mechanical, directional deformation from multiple simulations (plastic encapsulation + die attach + wafer bond + deposition) are added together to get the total deformation shown in the plot on the right. The slope of this graph is the “packaged strain” at -45 °C of Package Model C.

![Total deformation](image.png)

**Figure 12: Sum of deformation values from all packaging steps and high temperature deposition as a function of distance form die center. The slope is the packaged strain at -45 °C.**
Strain of packaged die across the operational temperature range

Sweeping the applied temperature—only on the plastic encapsulation step—and computing the sum of displacements along the scoped path resulting from all packaging steps, yields the strain across the operational temperature range (-45 °C to 155 °C) on all package models considered, plotted in Figure 13. Package models whose strain is the farthest from the unpackaged die are chosen (Packages A, B, and C), and linear best-fit equations are extracted for use in the subsequent modal analysis on the resonators. Additionally, as seen in Figures 14 (a) and (b), the packaged die deformation is isotropic, so the same displacement functions can be applied both in the lateral and transverse directions.

Figure 13: Lateral strain versus temperature for the unpackaged silicon die (solid black line) and packaged dies. Best-fit lines relate the strain to temperature, and these equations are used as nodal displacement functions for resonator anchors in the modal analysis.
Figure 14: Total deformation of packaged wafer in package model C. (a) at -45 °C and (b) at 155 °C. Deformation is isotropic and warpage is insignificant.
Temperature dependence of resonant frequency

Variation of Young’s modulus with temperature causes the resonant frequency of micromechanical resonators to be dependent on temperature. Additionally, since the resonator stiffness is susceptible to package-induced stress, thermal stability of both packaged and unpackaged micromechanical resonators must be simulated for comparison. The four geometries chosen for this work are 1) Clamped-clamped beam, 2) Free-free beam, 3) Center stem disk, and 4) Levitated disk.

ANSYS Mechanical [14] is used to simulate resonator temperature stability. Engineering data and geometry are defined in the Workbench interface as before. However, due to some limitations of the modal analysis in Workbench, this function is carried out through the use of APDL commands inserted in Mechanical. The code for the clamped-clamped beam is given as an example in Appendix C. Figures 15 and 17 show the quarter model of a clamped-clamped beam and a free-free beam resonator, respectively. As in the quarter package model, planes of symmetry are fixed in the direction normal to the plane and, since all package models showed minimal warpage on the packaged die surface, anchor nodes are fixed in the y-direction. Displacement as a function of the node x-coordinate and temperature for the unpackaged and packaged dies (taken from the trend lines of Figure 13) are expressed in Equations 1-4, where $U_{x, unp}$, $U_{x, A}$, $U_{x, B}$, and $U_{x, C}$ are the x-direction displacements of the unpackaged die, and packaged die in models A, B, and C, respectively, $T$ is the stressed temperature (applied thermal condition), and $x$ is the distance from die center.

\[
U_{x, unp} = 2.85 \times 10^{-6}(T - 600) \times x \quad (1)
\]
\[
U_{x, A} = (3.795 \times 10^{-6} \times T - 1.922 \times 10^{-3}) \times x \quad (2)
\]
\[
U_{x, B} = (3.037 \times 10^{-6} \times T - 1.789 \times 10^{-3}) \times x \quad (3)
\]
\[
U_{x, C} = (2.696 \times 10^{-6} \times T - 1.657 \times 10^{-3}) \times x \quad (4)
\]

The same equations are applied in the z-direction due to the isotropic nature of die deformation.
Figure 15: Finite element model showing solid elements of the clamped-clamped beam quarter model. Dimensions are given in Appendix A.

The finite element model is first solved for static loads (displacement and temperature), and the resulting deformation is examined to verify that the anchor moves by the amount predicted by Eqs. 1-4. By using the PSTRESS command, a stress stiffness matrix is calculated which is used in the subsequent prestressed modal analysis to determine the resonant frequency.

Figure 16: Static Deformation result showing CC beam anchor displacement due to package induced stress and applied temperature.
Figure 17: Finite element model showing solid elements of the free-free beam quarter model. Dimensions are given in the Appendix A.

After obtaining the static structural result and calculating stress stiffening effects, a modal analysis is now performed to calculate the resonant frequency of the desired mode shapes shown in Figure 19, determined using the Block Lanczos extraction method.
Unlike the beams, the disks selected for this work vibrate laterally. Mesh models and dimensions used for a centrally anchored disk and a disk levitated by four support beams on its perimeter, and their electrodes are shown in Figures 20 and 21. A static structural simulation shows that the lateral gap spacing changes significantly. The average gap spacing along the thickness of both disks is plotted in Figure 22.
Figure 20: Finite element model showing solid elements of the centrally anchored disk quarter model. Dimensions are given in the Appendix A. The electrode is suppressed in the prestressed modal analysis.

Figure 21: Finite element model showing solid elements of the levitated disk quarter model. Dimensions are given in Appendix A. The electrode is suppressed in the prestressed modal analysis.
Figure 22: Gap spacing simulation results for the unpackaged and packaged disk resonators. The gap is 130 nm at the stress free temperature of 600 °C.

As with the beams, anchor displacement expressions and temperature loads are applied, and the natural frequency of disks is determined using the Block Lanczos extraction method. Mode shapes are shown in Figure 23.

Figure 23: Desired mode shapes for the centrally anchored disk and levitated disk
Temperature Stability

Values for each resonator geometry (unpackaged and packaged, in ppm/°C) given in legend

Figure 24: Temperature stability results for selected packaged and unpackaged resonators. Resonator dimensions are given in Appendix A.
Conclusion

The results in Figure 13 explain the effect of die attach and cap wafer material properties, and die and wafer cap thicknesses on package strain. Reducing $t_{\text{cap}}$ and $t_{\text{die}}$ to 300 $\mu$m and using Pyrex as the cap wafer material seems to improve micromechanical temperature stability, although it is detrimental to package strain. This is because, of the three die attach materials used, the die attach used in standard IC packaging, which has a relatively high thermal expansion coefficient, compared to silver glass and polyimide, introduces more stress in the die. No significant difference was found when the ceramic substrate thickness was reduced to 1 mm.

The slope of the package strain lines can be thought of as an “effective coefficient of thermal expansion, $\alpha_{\text{eff}}$” which describes local behavior on the packaged die surface along the resonator anchor locations. Comparison of Figures 13 and 24 illustrates the direct correlation between $\alpha_{\text{eff}}$ and the temperature coefficient of frequency ($TC_f$), especially for the clamped-clamped beam. This is expected, because, of the various resonator geometries simulated, the CC beam is in direct contact with the substrate. Even though the FF beam has a large anchor area, it is levitated by support beams, and so, the package-induced stress related $TC_f$ is very close to the unpackaged value. The mechanical frequency of disks is nearly impervious to package induced stress for the reason that their anchor area is small.

Gap spacing results of Figure 22 show that larger $\alpha_{\text{eff}}$ results in a smaller gap. Also, all gap spacing values measured are larger than the stress free gap of 130 nm. This is because the structural material thermal expansion coefficient of 3.35 ppm/°C is much larger than that of the silicon substrate, 2.85 ppm/°C, so the polysilicon shrinks faster than the silicon, increasing gap spacing. When $\alpha_{\text{eff}}$ is larger than the silicon CTE, like in Package A, gap spacing increases with temperature. From the earlier analysis of the resonant frequency of the pure mechanical system for the disks, the change in gap spacing due to package-induced stress would be the most significant cause of resonant frequency shift, rather than anchor shift.

Traditional package-induced stress simulations in microelectronics aim to estimate the effect of residual stress, on properties like the input offset voltage of a differential op amp, by
examining die deformation. Although the micromechanical resonator stiffness is only altered by the displacement of anchor nodes, residual stress still needs to be studied for possibilities of mechanical failure, in the form of delamination, when shear stress exceeds a certain limit, or crack formation. Figure 25, left, shows contour plots of in-plane stresses at 155 °C, \( \sigma \), defined in (5) as the resultant of the x and y components of normal stress.

\[
\sigma = \sqrt{\sigma_{xx}^2 + \sigma_{yy}^2} \tag{5}
\]

The highest in-plane normal stress (175 MPa) appears in Package A, this value occurs at one corner of the die, and edge effects create a frame where the stress is around 115 MPa. The rest of the die sees very low stress values compared to the dies from the other packages. The die from Package C is under a very high stress value at its edge and the center contacting the die attach. This, together with the “effective \( \alpha_{eff} \)” being less than the silicon substrate CTE, reveals that the silver glass restricts die deformation so much that the surface nodes displace less than they do in the unpackaged die.

Apart from failure testing, the major factors needed for a more sophisticated simulation include material property accuracy, thermal cycling, and a lack of perfect adhesion between materials. Often, material properties fall in a range of values, rather than being exact. This phenomenon can be an outcome of the manufacturing methods and can be measured experimentally, and must be accounted for in more accurate package

Figure 25: In-plane normal stress (in MPa) results of the dies in (a) Package A, (b) Package B, and (c) Package C
stress calculations. For example, varying levels of voltage across the glass wafer in an anodic bond leads to compositional gradients, yielding different coefficient of thermal expansion (CTE) values across the wafer [17]. Soft materials, such as die attach and polymer, have different CTE values above and below the glass transition temperature. Also, polymers, die attach materials, and glass undergo chemical shrinkage (also a time dependent property) in addition to thermal contraction. This is modeled by experimentally measuring the directional deformation as a function of stress free temperature and then using a CTE that varies with stress free temperature in the simulation [5].

Thermal cycling tests reveal time-dependent material properties, which can be used in a transient analysis. This is especially useful, since, in practice, after each processing step, the assembly is cooled down to room temperature before being heated back to the elevated temperature to prepare for the next packaging step. This would occur several times throughout the packaging process and during the lifetime of the package. The authors of [16] have determined that the residual stress in some materials is highly dependent on the “dwell time”, the time that the assembly is subjected to a constant temperature. For soft materials such as the die attach adhesive and polymer, repeated heating and cooling may change the shape of the die attach and tilt the die (like in the X-ray images of [6]), resulting in an asymmetric package model.

Two possibilities can make the bonded contact assumption invalid. As discussed earlier, delamination may be a consequence of high shear stress, and can be simulated by slippage [5]. This model must be solved iteratively, by first calculating stress values resulting from a small temperature change, and then modifying contact elements that exceed the stress criterion, dictated by material properties, to non-bonded types in ANSYS (No separation, frictionless, frictional). This simulation must be repeated until the final temperature value. In the second case, the bonding material may have voids, resulting in loss of perfect adhesion [5] and can be modeled by a certain percentage of the contact area having a non-bonded contact type.

This work focusses on the temperature stability in sensors that are part of the original vision of a Smart Dust system [18], and hence, do not require further attachment to a printed circuit board (PCB). However, for applications such as cell phones and other portable electronics, where the packages are soldered to a PCB, additional stress is introduced due to the extra CTE mismatch. The PCB is also in tension since it’s mounted on the outer frame of the target application. For such
cases, a good understanding of the target application and manufacturing process is required, in order to perform a more complete analysis on temperature stability of the packaged resonators.

While the simulation procedure presented in this report can be used as a rough estimate on how the choices of package materials and geometry affect resonator thermal stability, the package model can be made more accurate by using experimental data to gain more insight into material properties. In some cases, a transient analysis would also be required.
References


[11] DuPont™ GreenTape™ low temperature co-fired ceramic system, Figure 9.


### Table 3: Beam frequency results and dimensions

<table>
<thead>
<tr>
<th>Temperature</th>
<th>Free-free beam</th>
<th>Clamped-clamped beam</th>
</tr>
</thead>
<tbody>
<tr>
<td>-45 °C</td>
<td>63.94978</td>
<td>104.1048</td>
</tr>
<tr>
<td>22 °C</td>
<td>63.86365</td>
<td>103.9467</td>
</tr>
<tr>
<td>155 °C</td>
<td>63.69235</td>
<td>103.6325</td>
</tr>
</tbody>
</table>

#### Frequency [MHz]

<table>
<thead>
<tr>
<th>Condition</th>
<th>Free-free beam</th>
<th>Clamped-clamped beam</th>
</tr>
</thead>
<tbody>
<tr>
<td>-45 °C</td>
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<td>104.1048</td>
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</tr>
<tr>
<td>155 °C</td>
<td>63.69235</td>
<td>103.6325</td>
</tr>
</tbody>
</table>

#### Frequency Shift [ppm]

<table>
<thead>
<tr>
<th>Condition</th>
<th>Free-free beam</th>
<th>Clamped-clamped beam</th>
</tr>
</thead>
<tbody>
<tr>
<td>-45 °C</td>
<td>1348.601</td>
<td>1449.177</td>
</tr>
<tr>
<td>22 °C</td>
<td>0</td>
<td>1580.17</td>
</tr>
<tr>
<td>155 °C</td>
<td>-2682.33</td>
<td>-3140.31</td>
</tr>
</tbody>
</table>

#### Thermal Stability [ppm/°C]

<table>
<thead>
<tr>
<th>Condition</th>
<th>Free-free beam</th>
<th>Clamped-clamped beam</th>
</tr>
</thead>
<tbody>
<tr>
<td>-45 °C</td>
<td>-20.1565</td>
<td>-21.6531</td>
</tr>
<tr>
<td>22 °C</td>
<td>-20.102</td>
<td>-23.6037</td>
</tr>
<tr>
<td>155 °C</td>
<td>-20.2642</td>
<td>-26.3072</td>
</tr>
</tbody>
</table>

#### Dimensions [μm]

- **R_f**: 16
- **W_f**: 8
- **t_r**: 2
- **L_n**: 3.5
- **L_s**: 5
- **W_s**: 1

### Table 4: Disk frequency results and dimensions

<table>
<thead>
<tr>
<th>Temperature</th>
<th>Center stem disk</th>
<th>Levitated disk</th>
</tr>
</thead>
<tbody>
<tr>
<td>-45 °C</td>
<td>186.4931</td>
<td>120.324</td>
</tr>
<tr>
<td>22 °C</td>
<td>186.2437</td>
<td>120.1629</td>
</tr>
<tr>
<td>155 °C</td>
<td>185.7476</td>
<td>119.8426</td>
</tr>
</tbody>
</table>

#### Frequency [MHz]

<table>
<thead>
<tr>
<th>Condition</th>
<th>Center stem disk</th>
<th>Levitated disk</th>
</tr>
</thead>
<tbody>
<tr>
<td>-45 °C</td>
<td>186.4931</td>
<td>120.324</td>
</tr>
<tr>
<td>22 °C</td>
<td>186.2437</td>
<td>120.1629</td>
</tr>
<tr>
<td>155 °C</td>
<td>185.7476</td>
<td>119.8426</td>
</tr>
</tbody>
</table>

#### Frequency Shift [ppm]

<table>
<thead>
<tr>
<th>Condition</th>
<th>Center stem disk</th>
<th>Levitated disk</th>
</tr>
</thead>
<tbody>
<tr>
<td>-45 °C</td>
<td>1339.11</td>
<td>1340.14</td>
</tr>
<tr>
<td>22 °C</td>
<td>0</td>
<td>1338.164</td>
</tr>
<tr>
<td>155 °C</td>
<td>-2663.56</td>
<td>-2665.6</td>
</tr>
</tbody>
</table>

#### Thermal Stability [ppm/°C]

<table>
<thead>
<tr>
<th>Condition</th>
<th>Center stem disk</th>
<th>Levitated disk</th>
</tr>
</thead>
<tbody>
<tr>
<td>-45 °C</td>
<td>-20.0152</td>
<td>-20.0306</td>
</tr>
<tr>
<td>22 °C</td>
<td>-20.0152</td>
<td>-20.0012</td>
</tr>
<tr>
<td>155 °C</td>
<td>-20.0153</td>
<td>-20.0247</td>
</tr>
</tbody>
</table>

#### Dimensions [μm]

- **R_f**: 16
- **t_r**: 2
- **L_s**: 5
- **W_s**: 1.5
Appendix B

To demonstrate the use of APDL command snippets in the package simulation, the following example is considered. At the die attach step, plastic solid elements and the plastic-to-ceramic contact pair are killed, and the reference temperature is now defined to be 350 °C, which overwrites the previously assigned stress free temperature.

The following APDL command is inserted under the plastic mold compound and die attach solid bodies to tag the solid plastic and die attach elements respectively.

*SET, EMC, MATID
*SET, DIE_ATTACH, MATID

The following APDL command is inserted under the plastic-to-ceramic contact pair to tag the contact and target elements accordingly.

MYCONT6=CID
MYTARG6=TID

Then, under the Static Structural environment, the EKILL command is used to kill the solid EMC elements and the EMC-to-LTCC contact and target elements. Note that killing a solid element multiplies its stiffness by $10^{-6}$ and does not actually delete the element from the model. MP, REFT overwrites the previously assigned stress free temperature.

ALLSEL, ALL
ESEL, S, MAT,, EMC
ESEL, A, TYPE,, MYCONT6
ESEL, A, TYPE,, MYTARG6
EKILL, ALL
MP, REFT, DIE_ATTACH, 350,
Appendix C

!! ANSYS APDL COMMANDS FOR PRESTRESSED MODAL ANALYSIS OF A CLAMPED-CLAMPED
!! BEAM THIS BEAM MODEL INCLUDES TRANS126 ELEMENTS TO INCORPORATE
!! ELECTRICAL STIFFNESS

ANTYPE, STATIC ! SET ANALYSIS TYPE TO
! STATIC

ALLSEL, ALL ! SELECT EVERYTHING
NSEL, S, LOC, Y, 0
CM, ANCHOR, NODE ! SELECT ANCHOR NODES
! GROUP SELECTED NODES INTO
! A COMPONENT NAMED “ANCHOR”

CMSEL, S, ANCHOR, NODE ! SELECT NODES OF COMPONENT
*GET, NCOUNT, NODE, 0, COUNT ! “ANCHOR”
*GET, NCURRENT, NODE, 0, NUM, MIN ! OBTAIN NUMBER OF NODES IN
! COMPONENT “ANCHOR”
*DO, I, 1, NCOUNT ! COUNTER TO SAVE THE
! SELECTED NODE NUMBER
! LOOP THROUGH NODES

*DO, I, 1, NCOUNT
! APPLY X-DISPLACEMENT, DETERMINED BY THE PACKAGE MODEL
! THAT VARIES WITH X-COORD AND TEMPERATURE ARG2
D, NCURRENT, UX, (ARG3*ARG2-ARG4)* NX(NCURRENT)

*DO, I, 1, NCOUNT
! APPLY Z-DISPLACEMENT, DETERMINED BY THE PACKAGE MODEL
! THAT VARIES WITH Z-COORD AND TEMPERATURE ARG2
D, NCURRENT, UZ, (ARG3*ARG2-ARG4)* NZ(NCURRENT)

CMSEL, S, ANCHOR, NODE ! SELECT NODES OF COMPONENT
NCURRENT=NDNEXT(NCURRENT) ! "ANCHOR"
! SELECT NODE HAVING A NODE
! NUMBER GREATER THAN
! NCURRENT

*ENDDO ! END DO-LOOP

ALLSEL, ALL ! SELECT EVERYTHING
CMSEL, S, ANCHOR, NODE ! SELECT NODES OF COMPONENT
D, ALL, UY, 0 ! “ANCHOR”
! FIX Y-DISP OF ANCHOR

ALLSEL, ALL ! SELECT EVERYTHING
CMSEL, U, ANCHOR, NODE ! UNSELECT “ANCHOR”
BF, ALL, TEMP, ARG2 ! APPLY TEMPERATURE OF VALUE
In the above code, ARG3, ARG2, and ARG4 are parameters that refer to package model (taken from the trend lines of Figure 13) and temperature variables, as in the following table:

<table>
<thead>
<tr>
<th>Applied Temperature, ARG2 [°C]</th>
<th>ARG3</th>
<th>ARG4</th>
</tr>
</thead>
<tbody>
<tr>
<td>Unpackaged</td>
<td></td>
<td></td>
</tr>
<tr>
<td>-45</td>
<td>2.850E-06</td>
<td>1.710E-03</td>
</tr>
<tr>
<td>22</td>
<td>2.850E-06</td>
<td>1.710E-03</td>
</tr>
<tr>
<td>155</td>
<td>2.850E-06</td>
<td>1.710E-03</td>
</tr>
<tr>
<td>Package A</td>
<td></td>
<td></td>
</tr>
<tr>
<td>-45</td>
<td>3.795E-06</td>
<td>1.922E-03</td>
</tr>
<tr>
<td>22</td>
<td>3.795E-06</td>
<td>1.922E-03</td>
</tr>
<tr>
<td>155</td>
<td>3.795E-06</td>
<td>1.922E-03</td>
</tr>
<tr>
<td>Package B</td>
<td></td>
<td></td>
</tr>
<tr>
<td>-45</td>
<td>3.037E-06</td>
<td>1.789E-03</td>
</tr>
<tr>
<td>22</td>
<td>3.037E-06</td>
<td>1.789E-03</td>
</tr>
<tr>
<td>155</td>
<td>3.037E-06</td>
<td>1.789E-03</td>
</tr>
<tr>
<td>Package C</td>
<td></td>
<td></td>
</tr>
<tr>
<td>-45</td>
<td>2.696E-06</td>
<td>1.657E-03</td>
</tr>
<tr>
<td>22</td>
<td>2.696E-06</td>
<td>1.657E-03</td>
</tr>
<tr>
<td>155</td>
<td>2.696E-06</td>
<td>1.657E-03</td>
</tr>
</tbody>
</table>